

# Siconnex BATCHSPRAY® Solvent: An investment in the future.



Siconnex BATCHSPRAY® Solvent can process different types of solvents. The equipment is used for substrates of 2" to 12" and is also compatible with Siconnex BATCHSPRAY® Autoload and the patented Retainer Comb Handling (RCH) System.



## ADVANTAGES

- For 2" to 12" substrates
- 25 or 50 Wafer chamber availability
- Left and right frame availability
- Less floorspace, due to 3 side service access
- Compatible with Autoload robot handling and the patented RCH System
- Standardized facility connections
- Accurate and powerful chemical in-line heaters
- Tank chiller units for temperature control
- High flow tank availability
- Bigger tank volume
- Up to 4 process tanks
- Direct process system for additional chemistry
- Extendible process chamber for easier service access



300 mm capable



## Process applications:



### CLEAN

- Polymer Clean
- Etch Residue Clean
- Post Ash Residue Clean



### RESIST STRIP

- Positive Resist Strip
- Negative Resist Strip



### RESIST DEVELOPING

- Photoresist Developing

**BATCHSPRAY®**  
**SOLVENT**